

## Carrier lifetime in erbium-doped GaN waveguide emitting in 1540 nm wavelength

Q. Wang, R. Hui, R. Dahal, J. Y. Lin, and H. X. Jiang

Citation: *Applied Physics Letters* **97**, 241105 (2010); doi: 10.1063/1.3527089

View online: <http://dx.doi.org/10.1063/1.3527089>

View Table of Contents: <http://scitation.aip.org/content/aip/journal/apl/97/24?ver=pdfcov>

Published by the [AIP Publishing](#)

---

### Articles you may be interested in

[Excitation cross section of erbium-doped GaN waveguides under 980nm optical pumping](#)

*Appl. Phys. Lett.* **105**, 051106 (2014); 10.1063/1.4892427

[1.54  \$\mu\$  m emitters based on erbium doped InGaN p-i-n junctions](#)

*Appl. Phys. Lett.* **97**, 141109 (2010); 10.1063/1.3499654

[Erbium-doped GaN optical amplifiers operating at 1.54  \$\mu\$  m](#)

*Appl. Phys. Lett.* **95**, 111109 (2009); 10.1063/1.3224203

[Time-resolved experimental study of carrier lifetime in GaN epilayers](#)

*Appl. Phys. Lett.* **87**, 241918 (2005); 10.1063/1.2146061

[Long carrier lifetimes in GaN epitaxial layers grown using TiN porous network templates](#)

*Appl. Phys. Lett.* **86**, 232106 (2005); 10.1063/1.1944903

---

**THE WORLD'S RESOURCE FOR  
VARIABLE TEMPERATURE  
SOLID STATE CHARACTERIZATION**

**WWW.MMR-TECH.COM**

OPTICAL STUDIES SYSTEMS    SEEBECK STUDIES SYSTEMS    MICROPROBE STATIONS    HALL EFFECT STUDY SYSTEMS AND MAGNETS

The advertisement for MMR Technologies features a blue and white color scheme. On the left is the MMR Technologies logo, which consists of a stylized 'M' and 'R' in a circular arrangement with the text 'MMR TECHNOLOGIES' below it. To the right of the logo is a grid of images showing various scientific instruments: a small white device, a blue box labeled 'SB1000', a blue box labeled 'K2000', a white circular probe station, a blue box labeled 'H5000', and a large white magnet assembly. Below the grid are four labels: 'OPTICAL STUDIES SYSTEMS', 'SEEBECK STUDIES SYSTEMS', 'MICROPROBE STATIONS', and 'HALL EFFECT STUDY SYSTEMS AND MAGNETS'. The website address 'WWW.MMR-TECH.COM' is displayed in red at the bottom left.

## Carrier lifetime in erbium-doped GaN waveguide emitting in 1540 nm wavelength

Q. Wang,<sup>1</sup> R. Hui,<sup>1,a)</sup> R. Dahal,<sup>2</sup> J. Y. Lin,<sup>2</sup> and H. X. Jiang<sup>2</sup>

<sup>1</sup>Department of Electrical Engineering and Computer Science, The University of Kansas, Lawrence, Kansas 66045, USA

<sup>2</sup>Department of Electrical and Computer Engineering, Texas Tech University, Lubbock, Texas 79409, USA

(Received 9 November 2010; accepted 22 November 2010; published online 16 December 2010)

We report the characteristics of an erbium-doped GaN semiconductor waveguide amplifier grown by metal-organic chemical vapor deposition. We demonstrated that both 980 and 1480 nm optical pumping were efficient to create population inversion between the  $^4I_{13/2}$  and  $^4I_{15/2}$  energy levels. The carrier lifetime in the  $^4I_{13/2}$  energy band was measured to be approximately 1.5 ms in room temperature, which is slightly shorter than that in erbium-doped silica due to the interaction between the erbium ions and the semiconductor lattice structure. But it is significantly longer than the carrier lifetime in a typical semiconductor optical amplifier which is in the nanosecond regime. © 2010 American Institute of Physics. [doi:10.1063/1.3527089]

Erbium (Er)-doped materials have attracted much attention for their applications in photonics, especially in the area of optical communications.<sup>1-3</sup> Doped in a solid host, Er<sup>3+</sup> ion has allowable intra-4f shell transition from its first excited state ( $^4I_{13/2}$ ) to the ground state ( $^4I_{15/2}$ ) and the transition corresponds to a wavelength of minimum optical loss in silica based optic fibers (1.55  $\mu\text{m}$ ).<sup>1-4</sup> Thus, Er-doped materials are ideal candidates to make amplifiers for optical communications. Today, Er-doped fiber amplifiers (EDFAs) are widely used in long-haul fiber-optic communications.<sup>1-4</sup> On the other hand, InGaAsP-based traveling-wave semiconductor optical amplifier (SOA) is electrically pumped and monolithically integratable with other components such as laser sources. However, due to the short carrier lifetime of a SOA, cross-saturation may cause significant interchannel crosstalk between different wavelength channels, which is a major problem preventing its practical applications in wavelength division multiplexing (WDM) systems.<sup>4</sup> In fact, short lifetime is intrinsic to free carriers involved in the band-edge recombination in most semiconductors.<sup>4,5</sup>

III-nitride semiconductors are excellent host materials for Er-ions due to their structural and thermal stabilities. III-nitride wide bandgap semiconductors have recently attracted much attention because of their applications in blue/UV optoelectronic devices as well as high power, high temperature electronic devices. Optical emission in 1.55  $\mu\text{m}$  wavelength window in Er-doped GaN films has been observed.<sup>6-9</sup> In particular, GaN and AlGaIn epilayers doped with Er-ions have demonstrated a highly reduced thermal quenching of the Er luminescence intensity from cryogenic to elevated temperatures as compared to other semiconductor host materials such as Si and GaAs. Optical amplification in Er-doped GaN waveguide has also been demonstrated using a 365 nm light emitting diode optical pumping source.<sup>10</sup> UV pumping above the GaN bandgap excited free electrons and holes and subsequently the electrons and holes transfer their energy to the doped erbium ions and produce sufficient carrier population on the  $^4I_{13/2}$  band which is responsible for emission in the 1550 nm wavelength window. This above bandgap excitation

was demonstrated to be more efficient than below bandgap excitation.<sup>11</sup>

Although EDFA in fiber-optic systems uses 980 or 1480 nm optical pumping,<sup>1</sup> investigations in Er-doped GaN so far were limited by using either green pump in 530 nm wavelength window<sup>12,13</sup> or UV pumping at 350 nm.<sup>10,11</sup> In fact, pumping at near infrared wavelengths to populate carriers in  $^4I_{13/2}$  energy band has an advantage of providing higher photon conversion efficiency than using higher energy photons such as in UV and green wavelengths, which avoided transitions through intermediate energy levels and the associated energy loss during these transitions.

The Er-doped GaN epilayers were synthesized by metal-organic chemical vapor deposition (CVD) in a horizontal reactor. Trimethylgallium was used for the Ga source, and blue NH<sub>3</sub> was used as the N source. The metal-organic precursor used for the *in situ* Er doping was tris(2,2,6,6-tetramethyl-3,5-heptanedionato) erbium, which was transported to the reactor by H<sub>2</sub>. All samples were grown on (0001) sapphire substrates. The growth of these epilayers began with a thin (~30 nm) GaN buffer layer, followed by a 1.4  $\mu\text{m}$  GaN epilayer template and a 0.5  $\mu\text{m}$  Er-doped GaN layer. The growth temperature of the GaN template and Er-doped GaN layer was 1040 °C. The waveguides were fabricated using

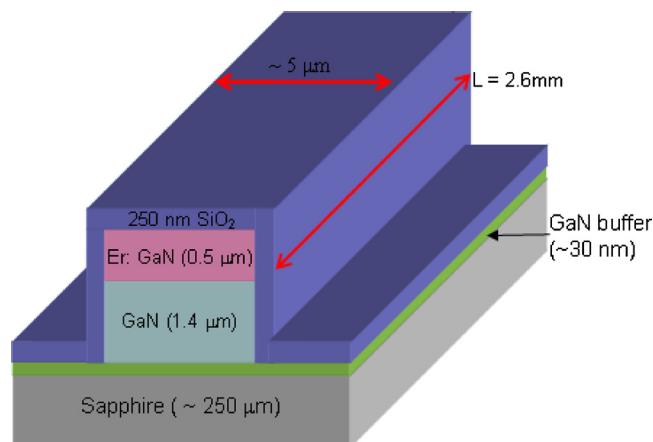


FIG. 1. (Color online) Layered structure of the Er-doped GaN waveguide.

<sup>a)</sup>Electronic mail: rhui@ku.edu.

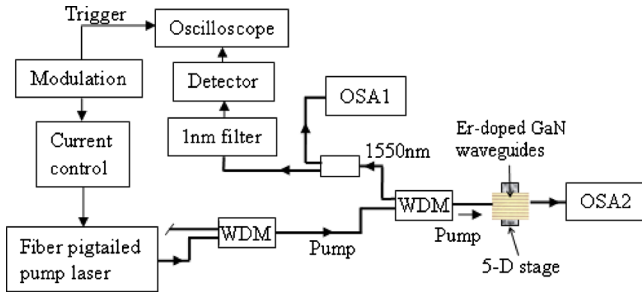


FIG. 2. (Color online) Experimental setup.

optical lithography and inductively coupled plasma dry etching. A 250 nm SiO<sub>2</sub> passivation layer was deposited on top of the waveguides by plasma enhanced CVD to reduce the optical scattering. The layered structure of the waveguide is shown in Fig. 1 which is about 5 μm wide and 2.6 mm long. The 0.5 μm thick Er-doped GaN layer has an Er concentration of approximately 5 × 10<sup>20</sup> cm<sup>-3</sup>. A numerical calculation using beam propagation method (BPM) software indicates that the overlap between the fundamental optical mode and the Er-doped layer is Γ=19.8%, which is commonly referred to as the field confinement factor.

The experimental setup is shown in Fig. 2. A fiber pigtailed laser diode, either at 980 or at 1480 nm, is coupled into the Er-doped GaN waveguide through two WDM fiber couplers which provide >40 dB isolation between the 1480 (or 980) and 1550 nm wavelength bands. A single mode fiber with a tapered tip was used to guide and focus the 1480 nm (or 980 nm) optical pump into the Er-doped GaN waveguide. The same fiber tip also collects the counterpropagating 1540 nm spontaneous emission generated from the waveguide and sends it to an optical spectrum analyzer (OSA1) for measurement. The spontaneous emission at 1537 nm was also selected by a bandpass optical filter for power measurement and the time-domain modulation response.

Figure 3 shows the measured spontaneous emission spectra when the waveguide was excited by 1480 and 980 nm optical pumping. The shape of the emission spectra did not change with different pump wavelengths, and in both cases, the emission covers approximately 30 nm optical bandwidth, which is comparable to that in Er-doped silica. When the pump power is high enough to achieve the highest carrier inversion between <sup>4</sup>I<sub>13/2</sub> and <sup>4</sup>I<sub>15/2</sub> energy levels, the peak emission density at 1537 nm reached to approximately -60 dBm for the resolution bandwidth of 2 nm with either pumping source. Considering an approximately -4 dB optical loss including the coupling loss from the waveguide to the fiber (3 dB) and the loss of the WDM coupler (1 dB), the

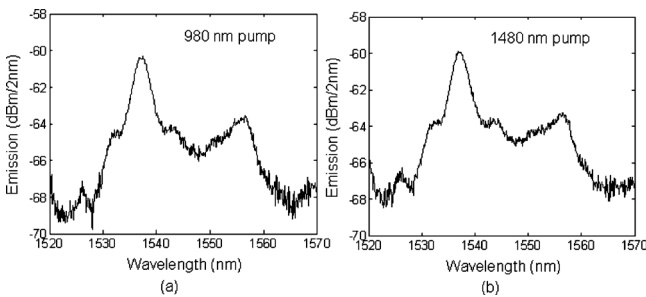


FIG. 3. Measured spontaneous emission spectra in 1540 nm window with 50 mW pump at 980 nm (a) and 30 mW pump at 1480 nm (b).

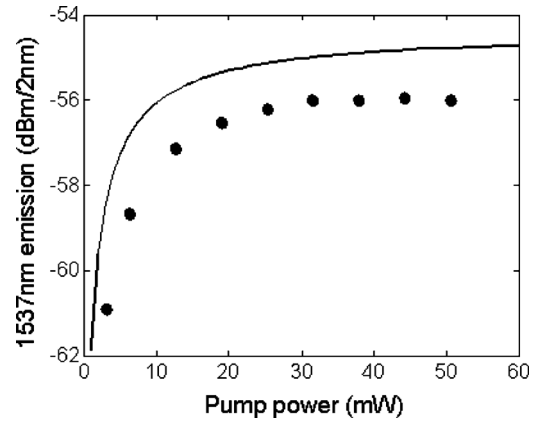


FIG. 4. Calculated (continuous line) and measured (dots) spontaneous emission power spectral densities at 1537 nm wavelength as functions of injected power of 1480 nm pump laser.

actual power spectral density emitted from the waveguide should be approximately -56 dBm/2 nm. This spontaneous emission power spectral density can be calculated by<sup>1</sup>

$$\rho_{ASE} = 2\Gamma\sigma_e(\lambda_s)hv_s \int_0^L \frac{N_T P_p e^{-2\alpha z} \sigma_a(\lambda_p)}{P_p e^{-\alpha z} [\sigma_a(\lambda_p) + \sigma_e(\lambda_p)] + hv_p A / \tau} dz, \quad (1)$$

where  $\sigma_e$  and  $\sigma_a$  are emission and absorption cross sections and  $N_T$  is the doping density of erbium ions.  $\lambda_p$  and  $\lambda_s$  are emission and pump wavelengths, respectively,  $\tau$  is the carrier lifetime,  $\Gamma$  is the field confinement factor,  $L$  is the length of the waveguide,  $hv_s$  and  $hv_p$  are photon energies at emission and pumping wavelengths,  $A$  is the waveguide cross section,  $\alpha$  is the attenuation coefficient, and  $P_p$  is the pump optical power. For such a short waveguide, we have neglected the saturation effect caused by spontaneous emission in the 1540 nm wavelength to simplify the calculation. Using the cross section values of erbium doped in silica glass and the pump wavelength at 1480 nm,<sup>14</sup>  $\sigma_a(\lambda_p)=1 \times 10^{-21}$  cm<sup>2</sup>,  $\sigma_e(\lambda_p)=0.5 \times 10^{-21}$  cm<sup>2</sup>, and  $\sigma_e(\lambda_s)=5 \times 10^{-21}$  cm<sup>2</sup>, and assuming the doping density of  $N_T=5 \times 10^{20}$  cm<sup>3</sup>, carrier lifetime  $\tau=1.5$  ms, and waveguide length  $L=2.6$  mm, the emission power spectral density can be calculated at 1537 nm wavelength, as shown in Fig. 4. We have also assumed the attenuation of the waveguide of 1.5 dB/mm.<sup>10</sup> With 50 mW pump power, the theoretical power spectral density emitted from the waveguide is -55 dBm/2 nm, which is about 1 dB higher than the measured value. This reduced efficiency is attributed to the nonradiative recombination and Auger recombination for the transition from the metastable level (<sup>4</sup>I<sub>13/2</sub>) to the ground level (<sup>4</sup>I<sub>15/2</sub>). Noting that although  $\sigma_a$  and  $\sigma_e$  values borrowed from erbium-doped silica may not be quantitatively accurate for GaN, the calculated result shown in Fig. 4 qualitatively agrees with the measurement, which provides a reasonable estimation of the pump efficiency.

In order to evaluate the dynamic response we passed the spontaneous emission through a 1 nm bandpass optical filter at 1537 nm and used an InGaAs photodiode to detect the optical power, and the waveforms were recorded by a real-time oscilloscope. By suddenly switching off the 1480 nm pump laser, the decay rate of the photoluminescence in 1537 nm is determined by the carrier lifetime on the <sup>4</sup>I<sub>13/2</sub> energy

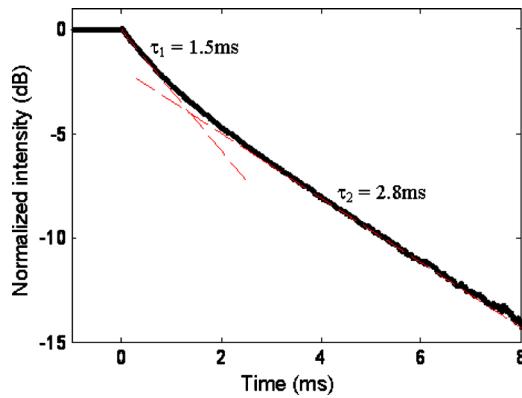


FIG. 5. (Color online) Falling edge of the measured spontaneous emission at 1537 nm wavelength after the pump laser at 1480 nm was switched off at  $t=0$ .

level. The measured falling edge of the spontaneous emission after switching off the pump shown in Fig. 5 exhibits a fast time constant of 1.5 ms and a slower time constant of 2.8 ms. The nonexponential decay indicated the existence of Auger recombination and cooperative upconversion<sup>14</sup> which is responsible for exciting carriers to higher energy levels.

Figure 6 shows the measured emission spectrum in the 400–1100 nm wavelength window using a charge coupled device-based optical spectrometer which is OSA2 in Fig. 2. Although the waveguide was excited by a 1480 nm pump, spectral components shown in Fig. 6 include the recombination from all the higher energy levels of Er-ion up to the  $^2H_{11/2}$ . This energy upconversion is attributed to the interaction between the doped Er-ions and the semiconductor lattice structure.

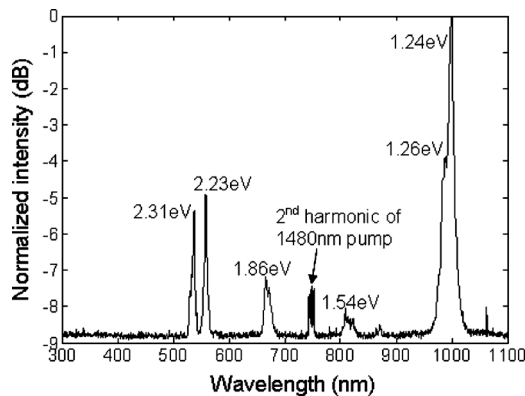


FIG. 6. Room temperature emission spectrum of Er-doped GaN waveguide in the short wavelength region with 1480 nm pumping.

In conclusion, we have measured the performance of an erbium-doped GaN waveguide for the potential application as an optical amplifier in 1540 nm wavelength window. By using 1480 and 980 nm pumping, which excited the carriers into the  $^4I_{13/2}$  energy band, the uncertainty of energy loss due to intraband transition was minimized in comparison with the short wavelength pumping in UV and green wavelength regions. A shorter carrier lifetime of 1.5 ms and a longer one of 2.8 ms were determined through the transient measurement of 1537 nm emission. The nonexponential decay indicated a cooperative upconversion at high pump power. This carrier lifetime is slightly shorter than that in EDFA due to the interaction between the erbium ions and the semiconductor lattice structure. But it is significantly longer than the carrier lifetime in a typical semiconductor optical amplifier which is in the nanosecond regime. The loss of 1540 nm emission efficiency of approximately 1 dB was determined primarily due to Auger recombination and cooperative upconversion.

This work was supported by the NSF (Grant No. ECCS-0854619). H.X.J. and J.Y.L. gratefully acknowledge the support of Ed and Linda Whitacre Endowed Chair positions through the AT & T Foundation.

<sup>1</sup>E. Desurvire, *Erbium-Doped Fibre Amplifiers: Principles and Applications* (Wiley, New York, 1994).

<sup>2</sup>R. J. Mears, L. Reekie, I. M. Jauncey, and D. N. Payne, *Electron. Lett.* **23**, 1026 (1987).

<sup>3</sup>P. C. Becker, N. A. Olsson, and J. R. Simpson, *Erbium-Doped Fibre Amplifiers: Fundamentals and Technology* (Academic, San Diego, CA, 1999).

<sup>4</sup>M. J. Connelly, *Semiconductor Optical Amplifiers* (Springer, Norwell, MA, 2002).

<sup>5</sup>S. Xu, J. B. Khurgin, I. Vurgaftman, and J. R. Meyer, *J. Lightwave Technol.* **21**, 1474 (2003).

<sup>6</sup>R. G. Wilson, R. N. Schwartz, C. R. Abernathy, S. J. Pearton, N. Newman, M. Rubin, T. Fu, and J. M. Zavada, *Appl. Phys. Lett.* **65**, 992 (1994).

<sup>7</sup>J. Michel, J. L. Benton, R. F. Ferrante, D. C. Jacobson, D. J. Eaglesham, E. A. Fitzgerald, Y. Xie, J. M. Poate, and L. C. Kimerling, *J. Appl. Phys.* **70**, 2672 (1991).

<sup>8</sup>M. Garter, J. Scofield, R. Birkhahn, and A. J. Steckl, *Appl. Phys. Lett.* **74**, 182 (1999).

<sup>9</sup>J. M. Zavada, S. X. Jin, N. Nepal, H. X. Jiang, J. Y. Lin, P. Chow, and B. Hertog, *Appl. Phys. Lett.* **84**, 1061 (2004).

<sup>10</sup>R. Dahal, C. Ugolini, J. Y. Lin, H. X. Jiang, and J. M. Zavada, *Appl. Phys. Lett.* **95**, 111109 (2009).

<sup>11</sup>R. Dahal, C. Ugolini, J. Y. Lin, H. X. Jiang, and J. M. Zavada, *Appl. Phys. Lett.* **93**, 033502 (2008).

<sup>12</sup>F. Pelle, F. Auzel, J. M. Zavada, D. S. Lee, and A. J. Steckl, *Mater. Sci. Eng., B* **105**, 126 (2003).

<sup>13</sup>I. Izuddin, T. Gregorkiewicz, D. S. Lee, and A. J. Steckl, *Superlattices Microstruct.* **36**, 701 (2004).

<sup>14</sup>E. Snoeks, G. N. van den Hoven, A. Polman, B. Hendriksen, M. B. J. Diemeer, and F. Priolo, *J. Opt. Soc. Am. B* **12**, 1468 (1995).